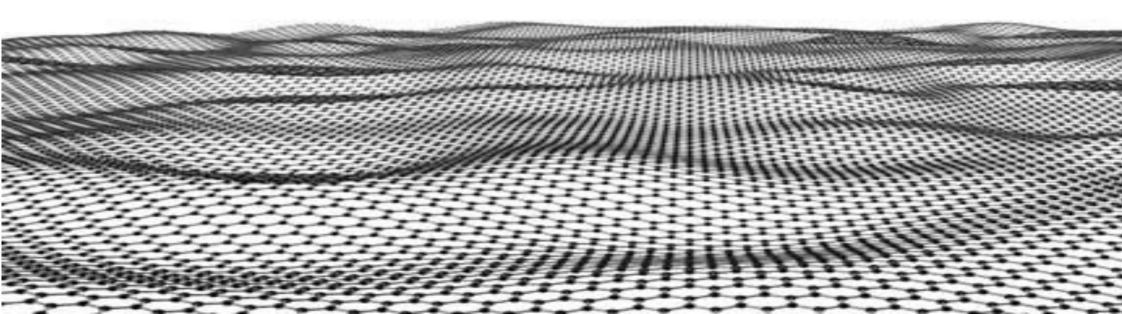
# Potential Applications for Graphene Devices in Nanoelectronics



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# Acknowledgement KTH

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Research Council

erc



# Graphene – Devices and Technology

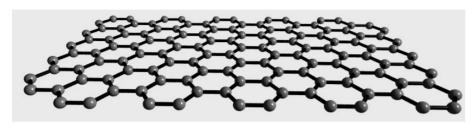
#### **Outline**

- Introduction
- Graphene Fabrication
- Graphene-based Electronic Devices
- Applications beyond "Moore's Law"
- Summary

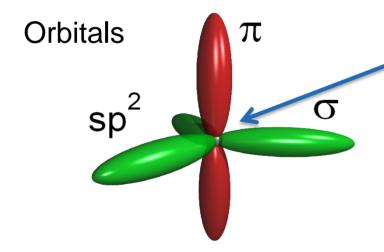


# **Graphene: Crystal Properties**

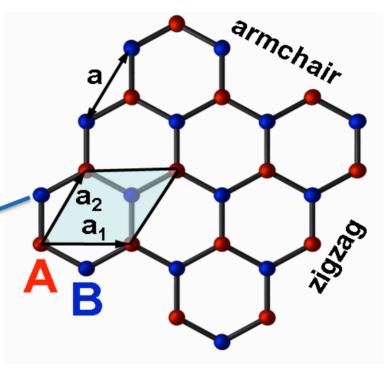
#### **Graphene**



sp<sup>2</sup> bonded carbon atoms (~4,3eV)



#### 2D-crystal lattice



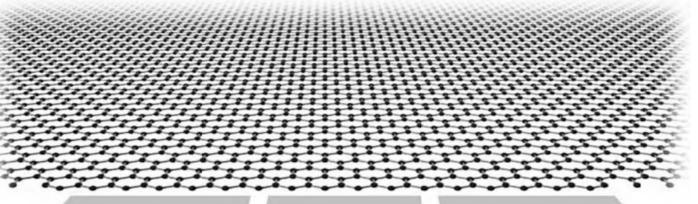
Sublattice constant: a = 0.246 nm

"Thickness": d = 0.34 nm

Lemme, Sol. St. Phenom., 2010

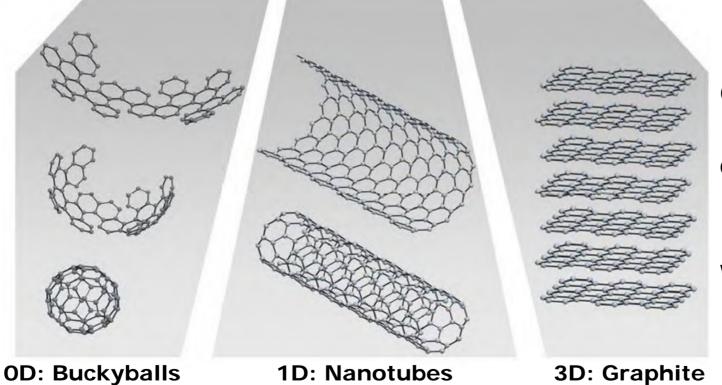


## "The mother of all graphitic forms"



2D: Graphene

Only one atom thick!



Graphite:

In plane: sp<sup>2</sup> bonded

carbon atoms

(~4,3eV)

Inter plane: weak v.d.

Waals bonds

 $(\sim 0.07 eV)$ 

1D: Nanotubes 3D: Graphite

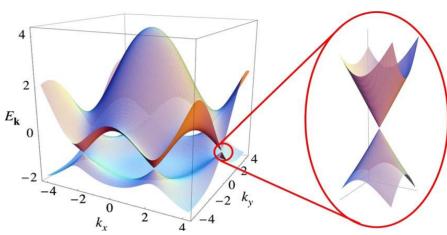
Nature Mater. 6., 183, 2007



# **Exceptional Properties (1/2)**

#### **Electronic properties**

- Semi-metal or zero-gap semiconductor E<sub>k</sub>
- Linear dispersion relation
   Optoelectronics
- Massless dirac fermions, v ~ c/300



After: Wallace, Phys. Rev. 71, 622 (1947).

- Intrinsic carrier mobility (suspended graphene in vacuum)
   200.000 cm<sup>2</sup> V<sup>-1</sup>s<sup>-1</sup>
- Carrier mobility of graphene on SiO<sub>2</sub> at room-temperature
   10.000-20.000 cm<sup>2</sup> V<sup>-1</sup>s<sup>-1</sup>
- Maximum current density

$$J > 10^8 \text{ A/cm}^2$$

Velocity saturation

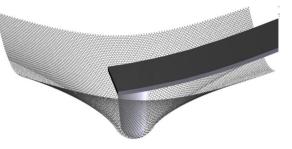
$$V_{sat} = 5 \times 10^7 \text{ cm/s} (10 \times \text{Si}, 2 \times \text{GaAs})$$



# **Exceptional Properties (2/2)**

#### Mechanical properties

- Young's modulus: ~1.10 TPa (Si ~ 130 GPa)
- Elastically stretchable by 20%
- "strongest material known"
- Flexible



Lee et al., Science, 385-388, 18 July 2008

#### Thermal conductivity

~5.000 W/m•K at room temperature

Diamond: ~2000 W/m•K, 10 x higher than Cu, Al

#### Thinnest material possible

#### Transparent (only 1 atom thin)

Transparent flexible conductive electrodes

#### High surface to volume ratio

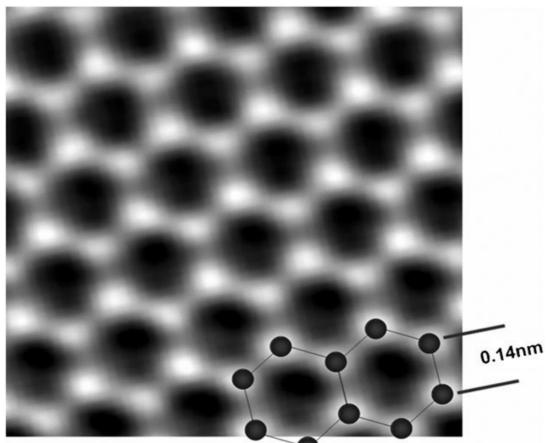
Sensors



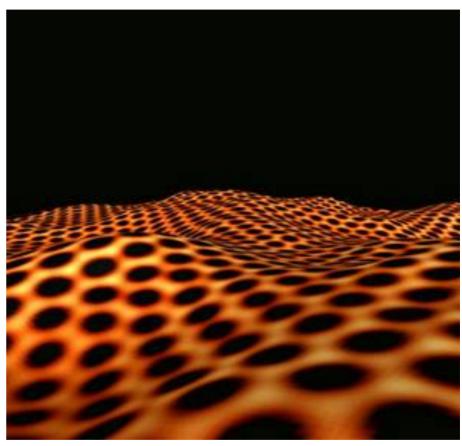
# **Graphene: Nanolandscapes**

Graphene by HRTEM...

and by STM



Aberration-corrected transmission electron microscope (TEAM 0.5)
Chem. Commun., 2009, 6095 - 6097



Scanning tunneling microscope image of graphene on SiO<sub>2</sub>
Mashoff et al, Nanoletters 2010



# Graphene – Devices and Technology

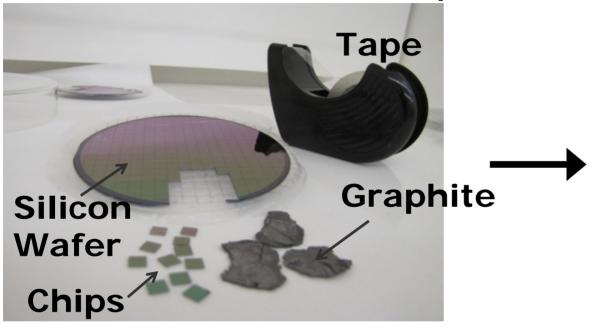
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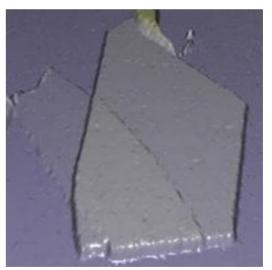
# **Graphene Fabrication Methods: Exfoliation**

#### **Exfoliation with adhesive tape**



- Novoselov et al., Science 306, 666 (2004)
- flake size: 5 100 μm
- random location
- simple process for proof-of-concept
- no industrial relevance



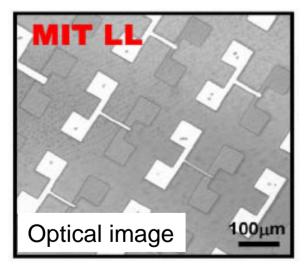




# **Graphene Fabrication Methods: Epitaxy**

#### Thermal decomposition of SiC (epitaxial graphene)

- Berger et al., J. Phys. Chem. B 108, 2004
- limited scalability
- high temperatures (~1500°C)
- high cost of material
- monolithic integration



Kedzierski et al., IEEE TED, 2008



Alternative approach: SiC growth on Silicon OSIRIS Project - M. Östling, M. Lemme, H. Radamson

- scalable
- modest temperatures (<1000°C)</li>
- Silicon Technology compatible

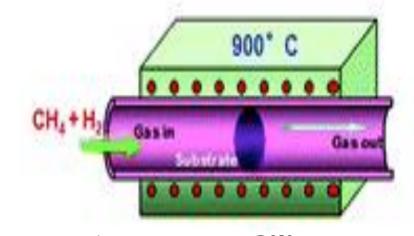


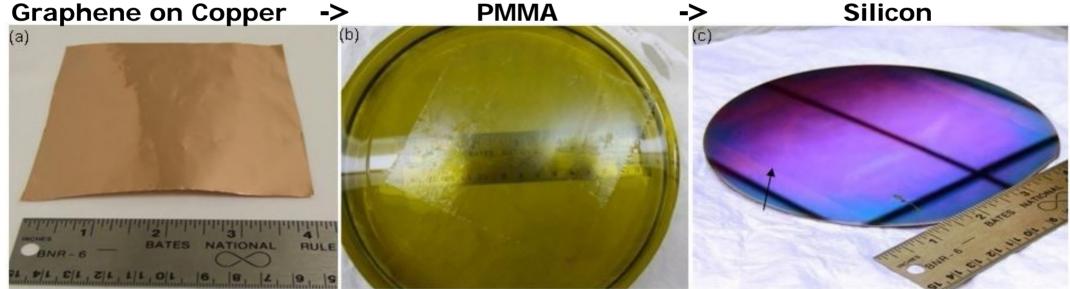


# **Graphene Fabrication Methods: CVD**

Chemical Vapor Deposition (CVD)

- CVD on Nickel, Copper, etc.
- High potential for large areas
- Graphene transfer to random substrates
- Monolayers vs. Multilayers?



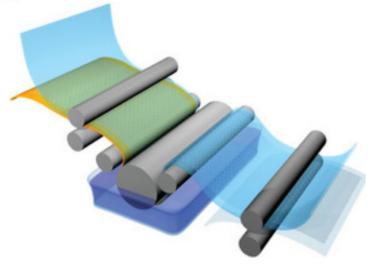


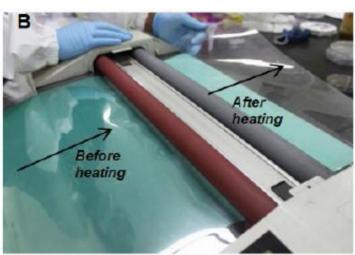
Cao et al, Applied Physics Letters 96, 122106 (2010)



# **Graphene Fabrication Methods: CVD**

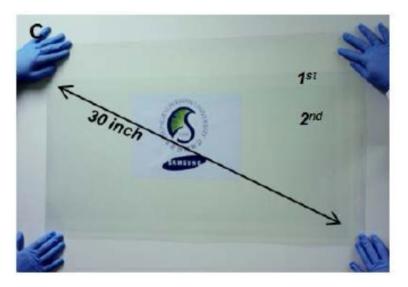
#### Roll-to-Roll Production





Bae et al. Nature Nanotech (2010)





In Europe: GRAFOL - Graphene Chemical Vapour Deposition: Roll to Roll Technology



# Graphene – Devices and Technology

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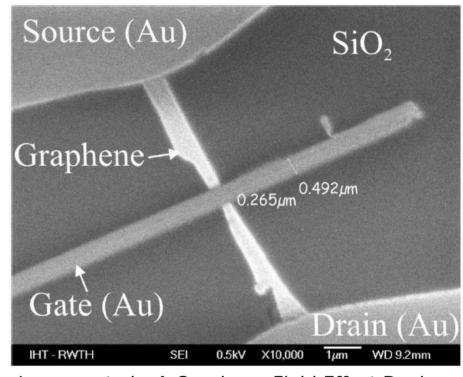
# **Graphene Transistors: Technology**

#### Silicon MOSFET

# FinFET drain gate fin source 200 nm

Source: TU Delft

#### **Graphene MOSFET**



Lemme et al. "A Graphene Field Effect Device", IEEE Electr. Dev. Lett. 28(4), 2007.

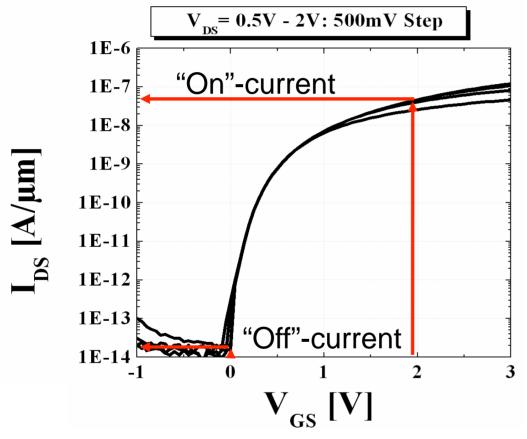
#### **Graphene Transistors:**

- Silicon process technology can be applied ("Top-Down")
- Graphene is compatible with (most) standard processes
- ... Graphene MOSFET!?



# **Graphene Transistors (GFETs)**

#### Silicon MOSFET



Schmidt et al., Sol. St. Electr., 2009

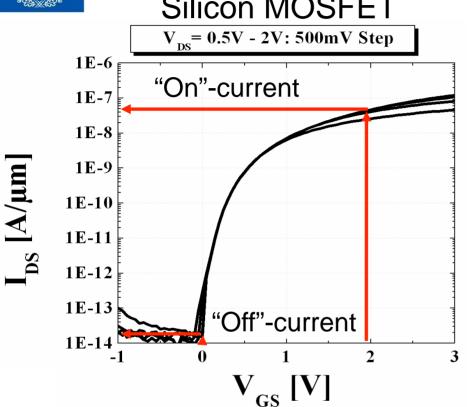
- Highly mature technology
- Billions of devices in parallel
- Near ideal switch
- I<sub>on</sub>/I<sub>off</sub> ratio: several decades
- Speed ~  $I_{on}$  ~  $\mu_{eff}$  (carrier mobility)

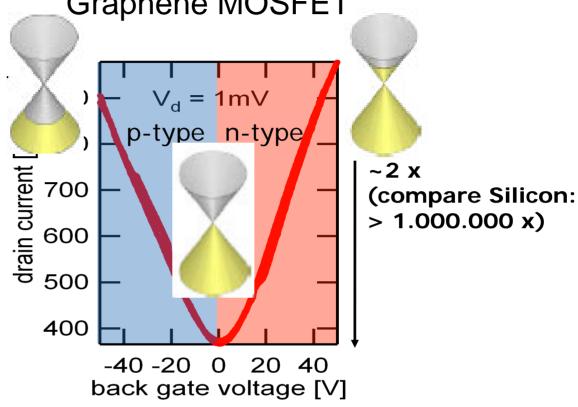
 $\mu$  - Silicon: 100-450 cm<sup>2</sup>/Vs

 $\mu$  - Graphene: 1.0000 – 200.000 cm<sup>2</sup>/Vs



# Graphene Transistors: Transfer Characteristics Silicon MOSFET V<sub>DS</sub> = 0.5V - 2V: 500mV Step





#### **Graphene Transistors:**

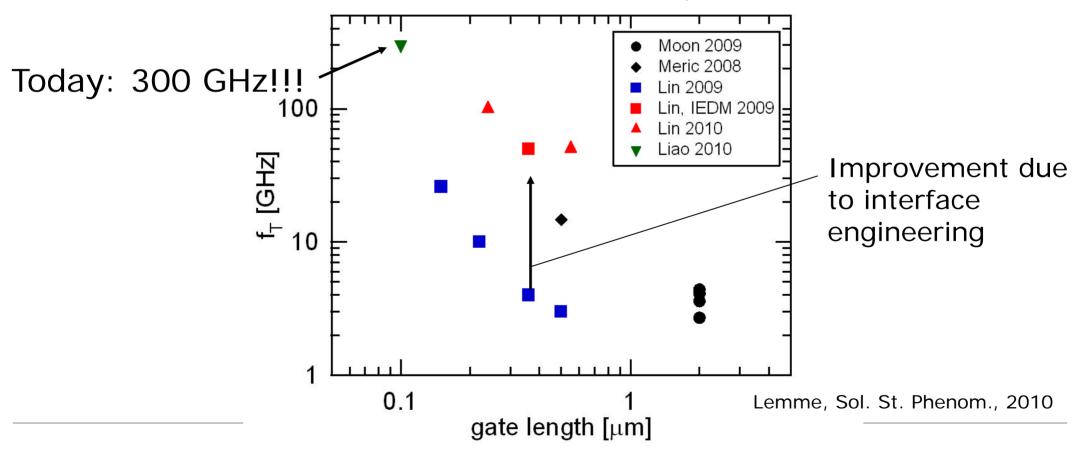
- Ambipolar behaviour (n- und p-type conduction)
- I<sub>on</sub>/I<sub>off</sub> ratio inherently limited by band structure (semimetall)
- NOT a direct replacement for Silicon logic, BUT...
- Higher functionality devices (e.g. frequency multipliers Palacios Group)
- ... High speed analog transistors



#### **RF Graphene Transistors**

- Exploiting high carrier mobility / velocity
- High on/off ratio not required

Development of cut-off frequency f<sub>T</sub> (12/2008-09/2010)





# **Performance Projections**

$$F_T = \frac{1}{2\pi} \frac{g_m}{C_G} \quad (C_G \text{ includes } C_{t-ox} \text{ and } C_q)$$

65nm GFET vs. Si-MOSFET

- $F_{T,MAX}$  of GFET almost as high as Si-CMOS at  $I_{DS} = 1\mu A$
- Si-CMOS  $F_{T,MAX}$  at higher current consumption than GFET  $F_{T,MAX}$
- GFETs achieve best performance in rather narrow I<sub>DS</sub> range
- "Dead zone" for GFET amplifiers
- Bilayer GFETs?

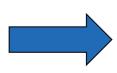
Rodriguez et al., arxiv 2011



# **Performance Projections**

 $GFET_{FT,MAX}$  vs. Mobility for L = 65 nm,  $T_{OX}$  = 2.6 nm, and  $\varepsilon_r$  = 3.9

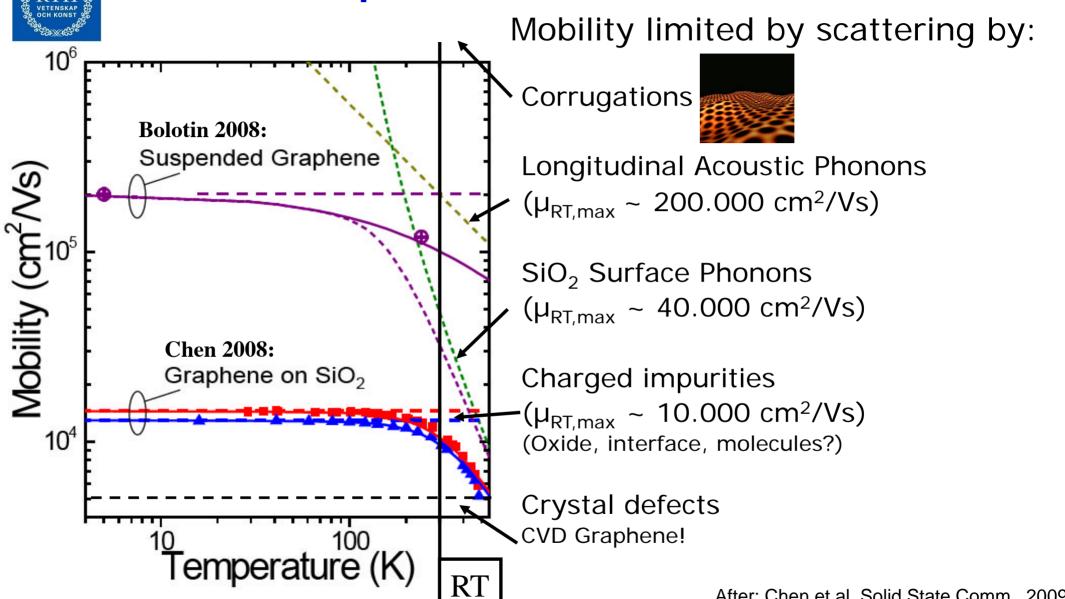
Rodriguez et al., arxiv 2011



- THz operation seems feasible for high mobility graphene
- → Graphene/insulator interface engineering
- → High quality CVD (or other) growth technique



# **Graphene Transistors: Fundamental Limits**

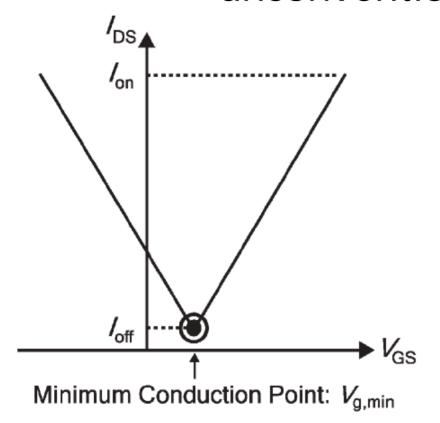


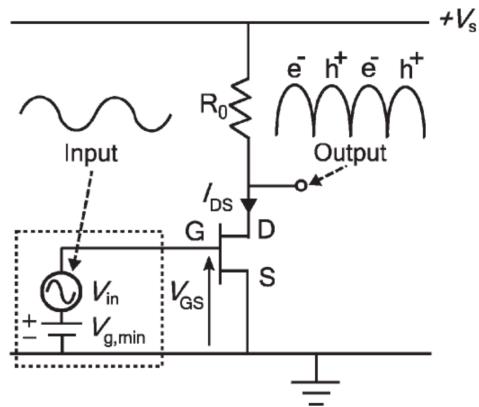
**NanoSpain** 

After: Chen et al. Solid State Comm., 2009

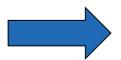


# Unconventional use of unconventional characteristics!?





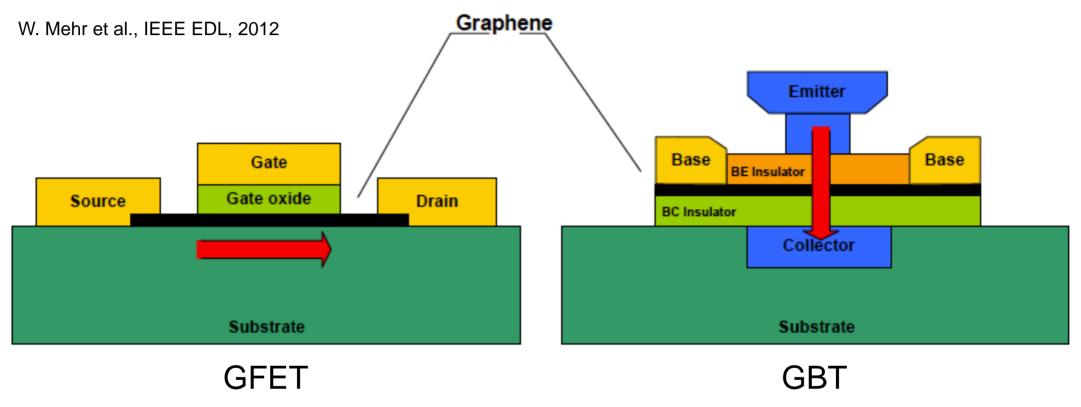
Wang et al., "Graphene Frequency Multipliers", IEEE EDL 5, 2009



- 1 Transistor Rectifier
- 1 Transistor Frequency Doubler



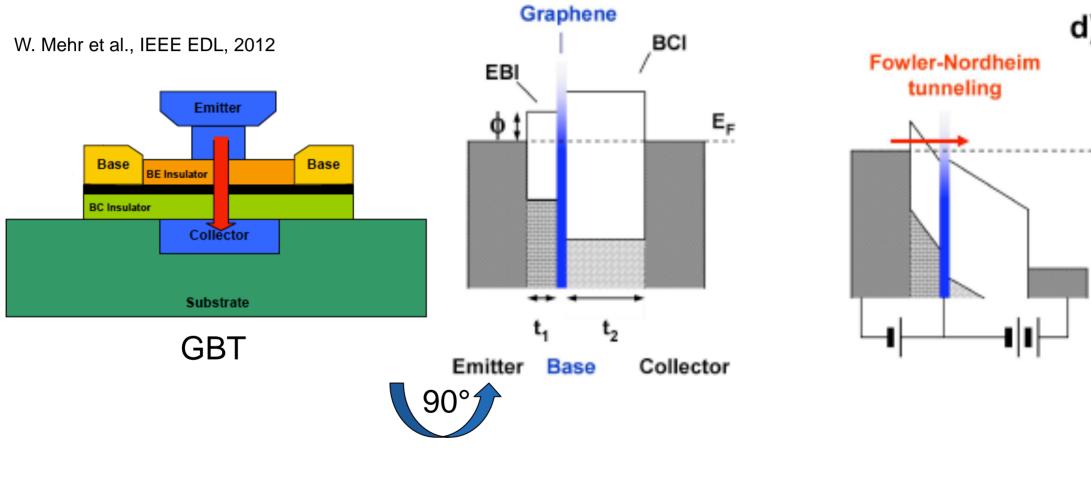
#### A new proposal: Graphene Base Transistor - GBT



- "Hot Electron" transistor
- Charge carriers are transported perpendicular to the graphene sheet
- Operation depends on quantum mechanical tunnelling



### A new proposal: Graphene Base Transistor - GBT



Potential Applications of Graphene

NanoSpain

**Unbiased** 

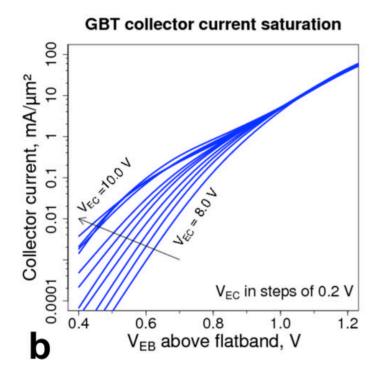
Max Lemme

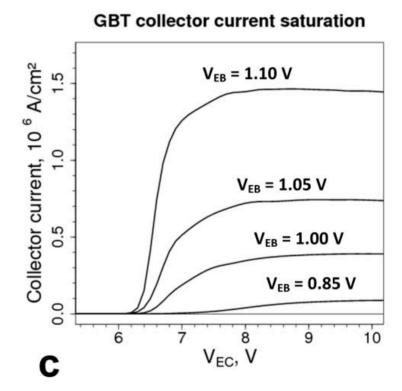
**Biased** 



#### A new proposal: Graphene Base Transistor - GBT

W. Mehr et al., IEEE EDL, 2012





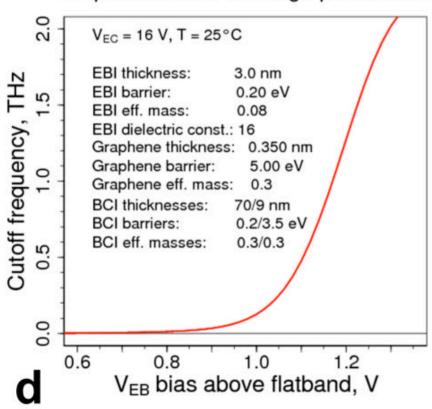
- Estimated transfer (b) and output (c) behavior
- Off-state expected to be well below on-state
- Current saturation
- Band structure needs careful engineering



# **Performance Projections**

W. Mehr et al., IEEE EDL, 2012

#### RF performance of a high power GBT





THz Operation seems feasible



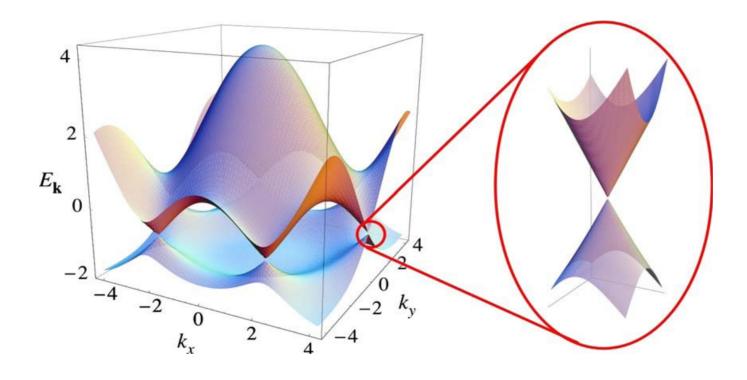
# Graphene – Devices and Technology

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- Applications beyond "Moore's Law"
  - Photodetection
- Summary



# **Graphene Optoelectronics**



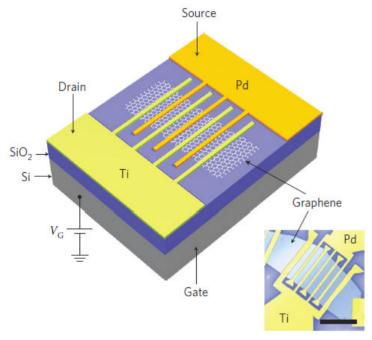
- E-k linear up to +- 1eV
- Potential from visible spectrum to THz
- High data rates

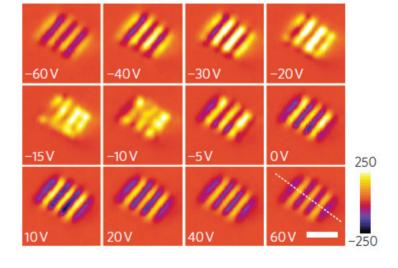


# **Graphene Optoelectronics**

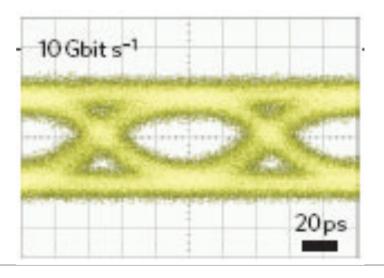
#### Graphene photodetectors for highspeed optical communications

Mueller et al., Nat. Photonics 2010





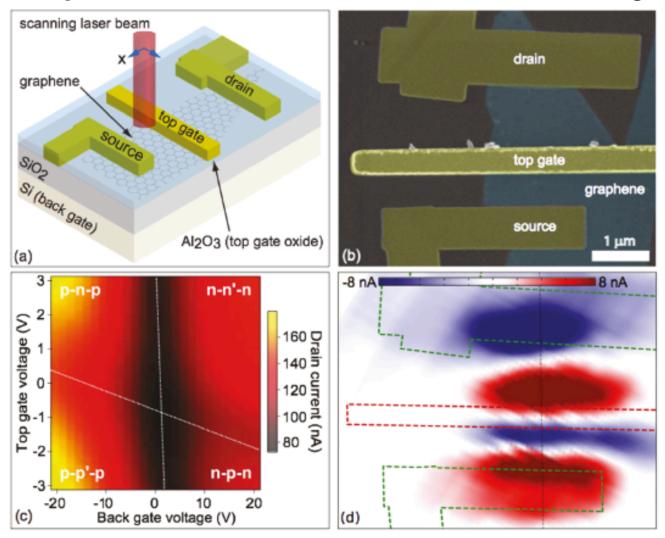
- Metal graphene interface induces pn-junction
- Control through back gate (substrate)
- Graphene "Eye Diagram"
- Error free optical data transmission at 10 Gbit/s





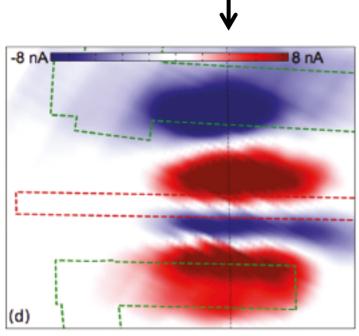
# **Graphene: Photodetection**

#### **Graphene Photodetectors: Local Tunability**



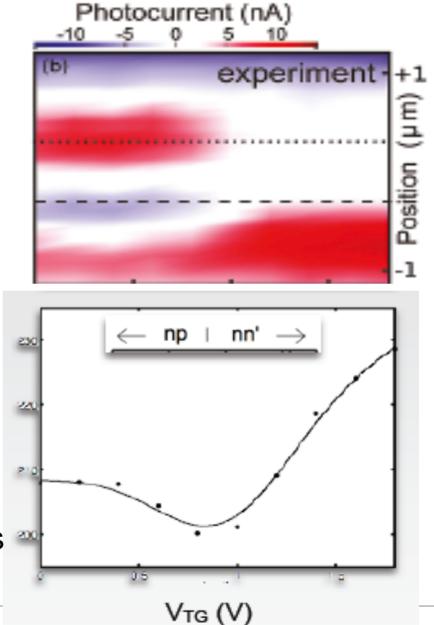
Lemme, Koppens, et al. "Gate Controlled Photocurrent in a Graphene p-n Junction", Nano Letters, 11, 2011.





- Strong photoresponse in pn junction
- Weak photoresponse in similar carrier gradient (nn' or pp')
  - Thermoelectric effect dominates a over photovoltaic effect

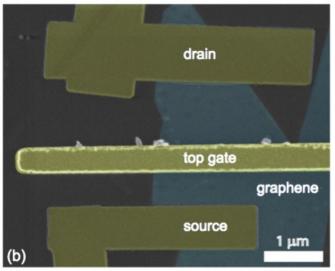
# **Graphene: Photodetection**

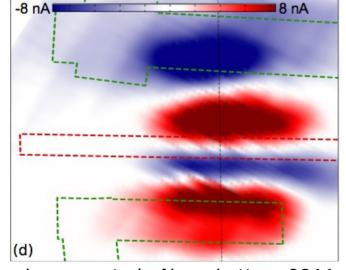




# **Graphene: Photodetection**







Lemme et al., Nano Letters 2011

#### **Graphene Photodetection**

- Strong contribution from Seebeck effect (pn-junction required)
- Local contol of p-n junction allows onoff control of photodetection.
- No biasing required (no dark current)
- Scalability to submicron gates
- Potential to integrate graphene optoelectronics into existing platforms
- Potential for UV to THz applications
- Enhanced quantum efficiency through carrier multiplication\*

\* Prediction: Song et al., Nano Letters 2011



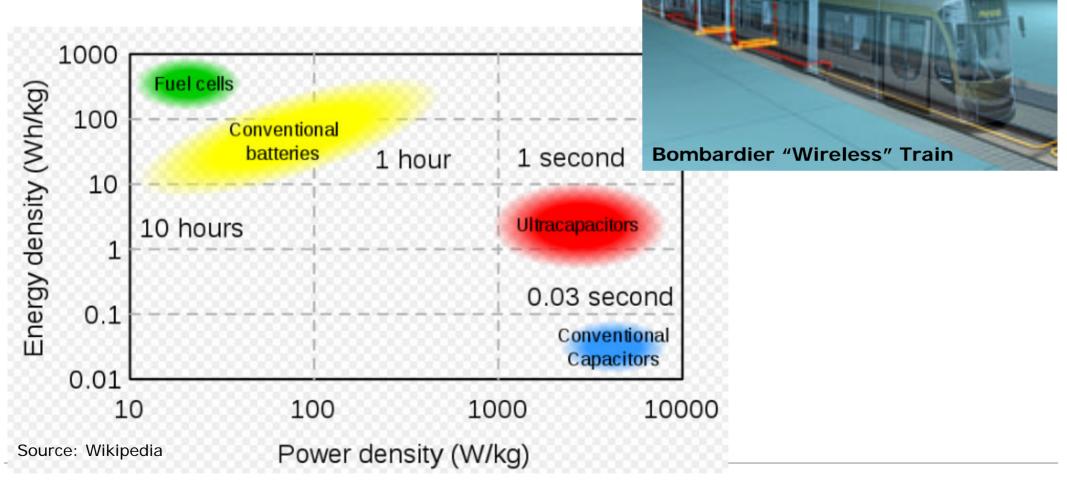
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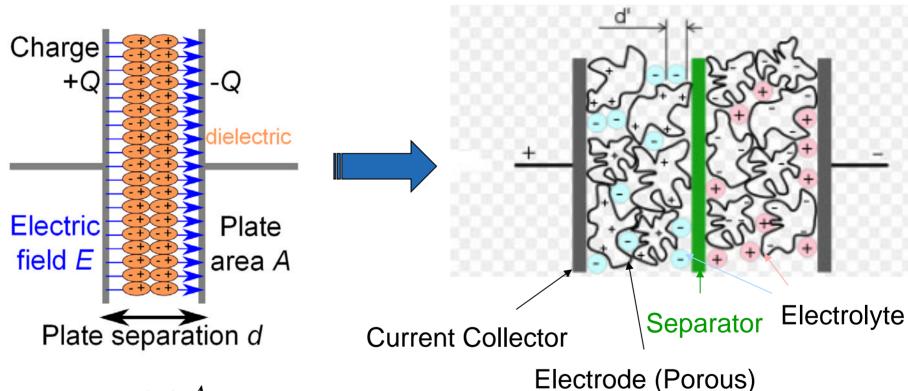


#### **Capacitor**

Direct Energy Storage Non-Faradaic Process

#### Supercapacitor, Ultracapacitor

Electrochemical Double Layer Capacitor High surface area (!)



$$C = \frac{\varepsilon_r \varepsilon_0 A}{d}$$

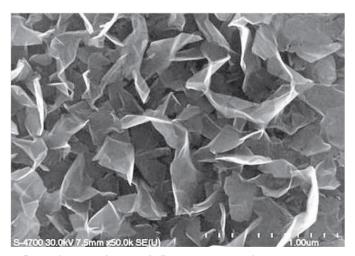
Source: Wikipedia



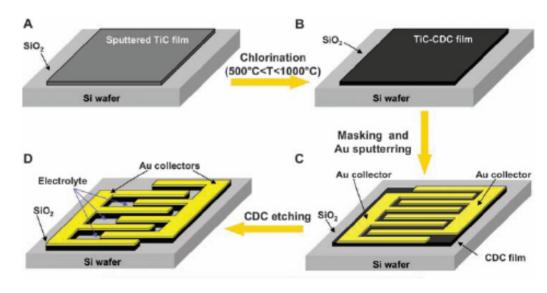
#### Graphene:

- comparable surface to volume ratio with porous carbon
- 10<sup>4</sup>-10<sup>5</sup> higher conductivity

#### Microelectronic Integration of Supercapacitors

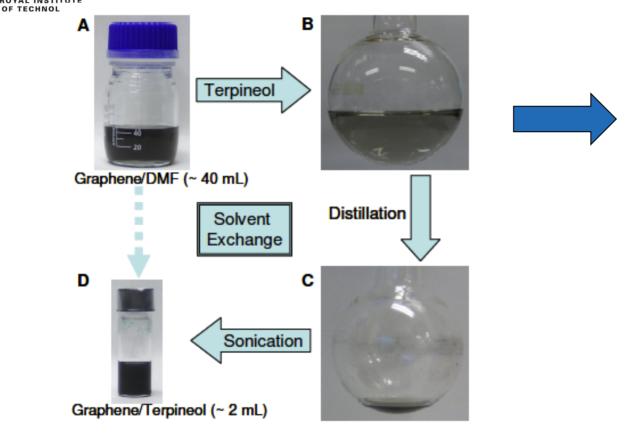


Graphene-based Supercapacitor, Science 329, 1637 (2010)

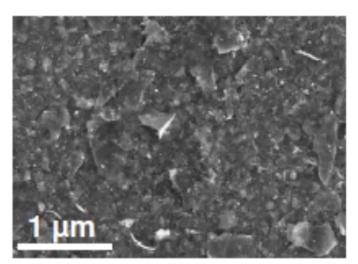


Chmiola et al., "Monolithic Carbide-Derived Carbon Films for Micro-Supercapacitors", Science **328**, 480 (2010)





- Graphene thin films from solution
- Transparent & conductive
- Inkjet-printable





Li, Lemme, Ostling, "A Simple Route towards High Concentration Surfactant-Free Graphene Dispersions", Carbon, 2012



# Graphene – Devices and Technology

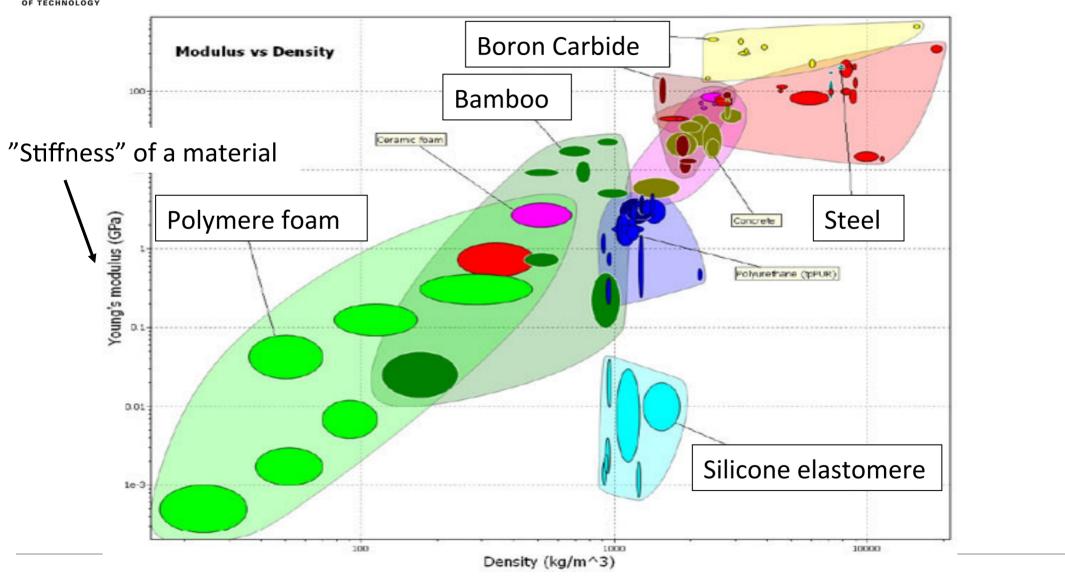
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# **Graphene Mechanics**

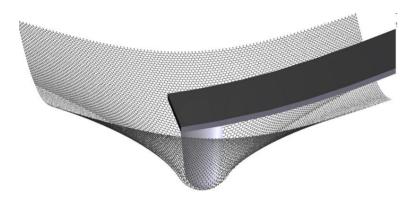
Graphene

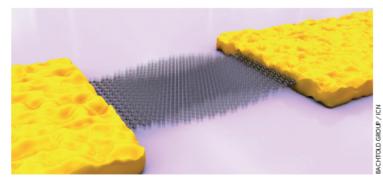




#### **NEMS**

Lee et al., Science, 385-388, 18 July 2008

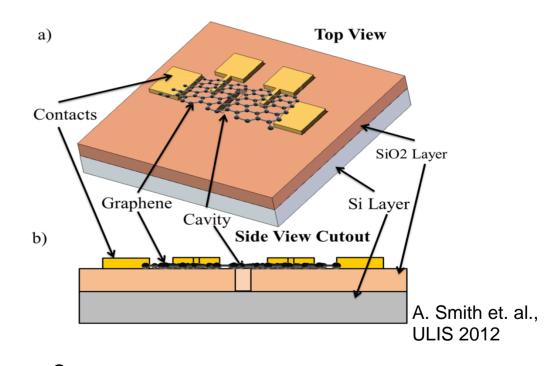


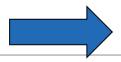


Source: A. Bachtold

# **Graphene Nanomechanics**

- Young's modulus: ~1.10 TPa (Si ~ 130 GPa)
- Elastically stretchable by 20%
- High mechanical stability
- "strongest material known"
- Flexible
- Low mass

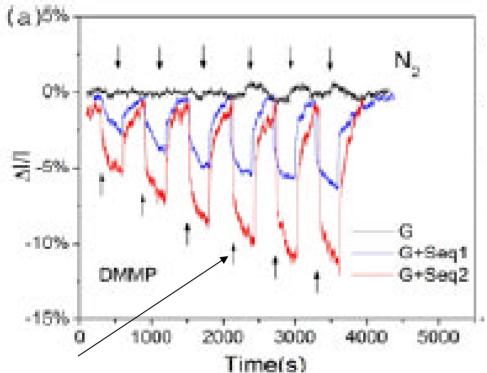




Graphene based mass, force, pressure sensors



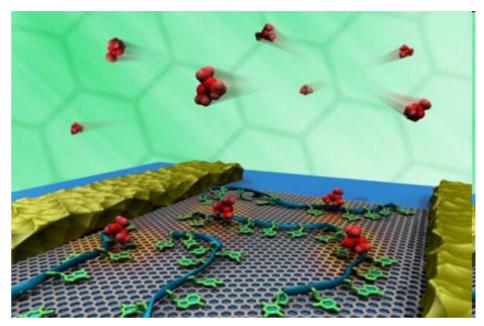
# DNA decorated graphene chemical sensors



Introduction of analyte at progressively larger concentrations

Lu et al., Appl. Phys. Lett. 97, 083107 (2010)

# **Graphene Sensors**



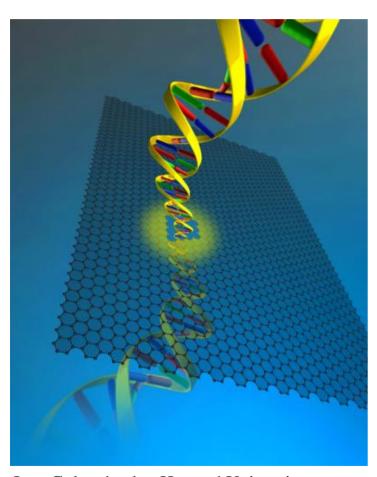
Source: Robert Johnson, Temple University

- Clean graphene devices show very weak vapor response
- Devices functionalized (red & blue data) show significant sequencedependent responses



# **Graphene Sensors**

#### DNA sequencing using nanopores in graphene



Jene Golovchenko, Harvard University.

#### Why graphene?

- High mechanical strength
- High electric conductivity
- Ultimately thin



# Graphene – Devices and Technology

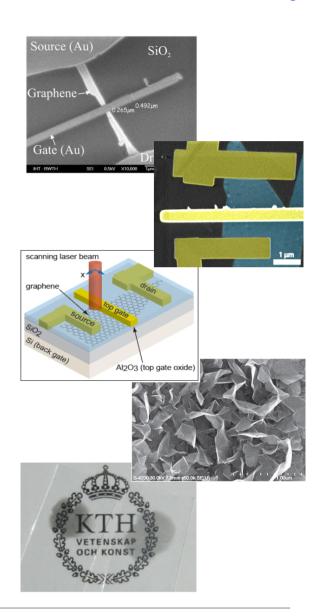
#### **Outline**

- Introduction
- Graphene Fabrication
- Graphene-based Electronic Devices
- Applications beyond "Moore's Law"
- Summary



# **Summary**

- Graphene is a "Serious" Electronic Material
- Large Area Manufacturing Available
- Electronic Applications
  - Analog Transistors
  - Optoelectronics
  - Printable Electronics
  - Supercapacitors
  - Transparent Electrodes
  - Interconnects
  - Passives, Antennas





# **Graphene: Research Topics**

- NEMS
- Mechanical Applications (Space Elevator)
- Sensors (Functionalized Surfaces, Biocompatibility)
- Resistive Switching (Memory Applications)
- Ballistic Devices
- Spintronics (Spin-Valves, SpinMOSFET, SpinFET)
- ...other 2D Materials (h-BN, MoS2...)



# **Graphene – Enabling New Gadgets?**

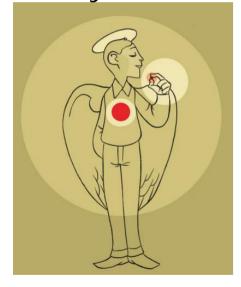
**Smart Monitoring** 

Wearable Electronics





**Body Sensors** 





- > 24 Universities, research institutions & industry
- Energy Harvesting
- Wireless Sensor Networks
- Health, Safety and Environmental monitoring
- Bid for 10 year, 1 billion EUR flagship project
- http://www.ga-project.eu